## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

Naoki YAMAMOTO

Serial No.:

Not yet assigned

Divisional Application of Serial No. 09/639,306, Issued as

Patent No. 6,645,799

Filed:

Even date herewith

For:

METHOD OF MANUFACTURING A DUAL GATE SEMICONDUCTOR DEVICE WITH A POLY-METAL

**ELECTRODE** (As Amended)

Group:

2813 (expected)

Examiner:

Jack S. J. Chen (expected)

## **CLAIM FOR PRIORITY**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

February 27, 2004

Sir:

Pursuant to 35 U.S.C. §119 and 37 CFR 1.55, the applicants hereby claim the right of priority based on the following foreign applications filed in Japan:

Application No. 2000-017875 filed on January 24, 2000.

A certified copy of this foreign application was filed on September 27, 2000, in application Serial No. 09/639,306, the parent application of the present divisional application.

Respectfully submitted,

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HHB:btd